

ABSTRACT

A polishing liquid comprising an abrasive grain, an additive, and water, wherein the abrasive grain includes a hydroxide of a tetravalent metal element, produces absorbance of 1.00 or more for light having a wavelength of 400 nm in an aqueous dispersion having a content of the abrasive grain adjusted to 1.0 mass%, and produces light transmittance of 50%/cm or more for light having a wavelength of 500 nm in an aqueous dispersion having a content of the abrasive grain adjusted to 1.0 mass%, and a difference between a NO_3^- concentration of an aqueous dispersion having a content of the abrasive grain adjusted to 1.0 mass% and a NO_3^- concentration after retaining the aqueous dispersion at 60°C for 72 hours is 200 ppm or less.